L Number	Hits	Search Text	DB	Time stamp
_	1	"036869"	US-PGPUB	2003/05/02 09:09
-	. 0	"036898"	US-PGPUB	2003/05/02
-	1	Shao-Yen.in.	USPAT	2003/05/02
-	10426	(NH?sub.40H or ammonia or (ammonium adj hydroxide)) same (poly or polysilicon or	USPAT	2003/10/08 15:15
-	436	<pre>(polycrystalline adj silicon)) ((NH?sub.40H or ammonia or (ammonium adj hydroxide)) same (poly or polysilicon or (polycrystalline adj silicon))) same</pre>	USPAT	2003/10/09 10:14
-	341	(selective or selectivity or selectively) (((NH?sub.4OH or ammonia or (ammonium adj hydroxide)) same (poly or polysilicon or (polycrystalline adj silicon))) same (selective or selectivity or	USPAT	2003/05/02 09:18
.=	227	selectively)) and (remove or removing or etch or etching or clean or cleaning) ((((NH?sub.4OH or ammonia or (ammonium adj hydroxide)) same (poly or polysilicon or (polycrystalline adj silicon))) same (selective or selectivity or	USPAT	2003/05/02 09:19
·		selectively)) and (remove or removing or etch or etching or clean or cleaning)) and (water or DI or DIW or deionize or H?sub.20)		
-	825	(NH?sub.40H or (ammonium adj hydroxide)) same (poly or polysilicon or (polycrystalline adj silicon))	USPAT	2003/05/02 13:09
-	88	((NH?sub.40H or (ammonium adj hydroxide)) same (poly or polysilicon or (polycrystalline adj silicon))) same	USPAT	2003/05/02 09:30
-	254	(selective or selectivity or selectively) (NH?sub.4OH or (ammonium adj hydroxide)) with (poly or polysilicon or	USPAT	2003/05/02 10:09
-	84	<pre>(polycrystalline adj silicon)) ((NH?sub.40H or (ammonium adj hydroxide)) with (poly or polysilicon or (polycrystalline adj silicon))) and (selectivity or selective or selectively or (rate near3 ratio))</pre>	USPAT	2003/05/02 10:10
-	53	<pre>(((NH?sub.40H or (ammonium adj hydroxide)) with (poly or polysilicon or (polycrystalline adj silicon))) and (selectivity or selective or selectively or (rate near3 ratio))) not ((NH?sub.40H or (ammonium adj hydroxide)) same (poly</pre>	USPAT	2003/05/02
	31	or polysilicon or (polycrystalline adj silicon))) same (selective or selectivity or selectively)) (((NH?sub.4OH or (ammonium adj	ИСРАЩ	2002/05/02
	31	hydroxide)) with (poly or polysilicon or (polycrystalline adj silicon))) and (selectivity or selective or selectively or (rate near3 ratio))) not ((((NH?sub.40H or (ammonium adj hydroxide)) with (poly or polysilicon or (polycrystalline adj silicon))) and (selectivity or selective or selectively or (rate near3 ratio))) not (((NH?sub.40H or (ammonium adj hydroxide)) same (poly	USPAT	2003/05/02
_	36	or polysilicon or (polycrystalline adj silicon))) same (selective or selectivity or selectively))) ((NH?sub.40H or (ammonium adj hydroxide))	USPAT	2003/05/02
		same (poly or polysilicon or (polycrystalline adj silicon))) and (native near3 oxide)		13:26

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				10000105100
-	730	, ,	USPAT	2003/05/02
		hydro\$1fluoric)		13:26
-	190	((native near3 oxide) with (HF or	USPAT	2003/05/02
		hydro\$1fluoric)) same (rinse or water or		13:27
		rinsing)		
-	67	(((native near3 oxide) with (HF or	USPAT	2003/05/02
		hydro\$1fluoric)) same (rinse or water or		13:41
		rinsing)) and polysilicon		
_	6		USPAT	2003/05/02
		hydro\$1fluoric)) same (rinse or water or	001111	13:41
		rinsing)) and polysilicon) and (second		13.41
		adj polysilicon)		
	10758	1 3 1 1	USPAT	2002/10/00
_	10/58	, ,	USPAT	2003/10/08
		hydroxide)) same (poly or polysilicon or		15:41
	5.450	(polycrystalline adj silicon))		0000/10/00
-	5478		USPAT	2003/10/08
		hydroxide)) with (poly or polysilicon or		15:44
		(polycrystalline adj silicon))		
_	1472	((NH?sub.40H or ammonia or (ammonium adj	USPAT	2003/10/08
		hydroxide)) with (poly or polysilicon or		15:45
		(polycrystalline adj silicon))) and		
		(selective or selectively or selectivity)		
-	229	((NH?sub.40H or ammonia or (ammonium adj	USPAT	2003/10/08
		hydroxide)) with (poly or polysilicon or		15:45
		(polycrystalline adj silicon)))		
		same(selective or selectively or		
		selectivity)		
	1	1,	1	